Title (en)

GLASS SUBSTRATE WITH SLIGHTLY ROUGH LAYER

Title (de)

GLASSUBSTRAT MIT LEICHT RAUER SCHICHT

Title (fr)

SUBSTRAT VERRIER A COUCHE FAIBLEMENT RUGUEUSE

Publication

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Application

EP 12718284 A 20120330

Priority

- FR 1152873 A 20110404
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Abstract (en)

[origin: WO2012136919A1] The invention relates to - a glass substrate, characterized in that it is provided with a layer constituted of crystallites of at least 25 nm, covered directly with a layer constituted of crystallites of at most 10 nm; - the process for manufacturing same; - the applications thereof in a photovoltaic cell electrode, as low-emissivity glazing or in solar control.

IPC 8 full level

C03C 17/34 (2006.01); **C23C 14/00** (2006.01)

CPC (source: EP KR US)

B32B 9/04 (2013.01 - US); **C03C 17/23** (2013.01 - US); **C03C 17/34** (2013.01 - KR); **C03C 17/3417** (2013.01 - EP US); **C03C 17/3441** (2013.01 - EP US); **C23C 14/00** (2013.01 - KR); **C23C 16/407** (2013.01 - EP US); **F24C 15/04** (2013.01 - US); C03C 2217/77 (2013.01 - EP US); C03C 2217/94 (2013.01 - EP US); C03C 2218/1525 (2013.01 - EP US); Y10T 428/265 (2015.01 - EP US)

Citation (search report)

See references of WO 2012136919A1

Citation (examination)

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